



Sheet 1 of 1 sheet(s)

U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified)		Docket No. NVDA P001025	Serial No. 10/727,822
LIST OF PATENTS AND PUBLICATIONS CITED BY APPLICANT		Applicant Henry P. Moreton et. al.	Confirmation No. Unknown
(Use several sheets if necessary)		Filing Date December 3, 2003	Group Unknown
Examiner Unassigned			

**U.S. Patent Documents**

*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
	1						
	2						
	3						
	4						
	5						

**Foreign Patent Documents**

*Examiner Initial		Document Number	Date	Country	Class	Subclass	Translation	
							YES	NO
	6						<input type="checkbox"/>	<input type="checkbox"/>
	7						<input type="checkbox"/>	<input type="checkbox"/>
	8						<input type="checkbox"/>	<input type="checkbox"/>

**OTHER ART**

*Examiner Initial		Including Author, Title, Date, Pertinent Pages, Etc.
<i>hm</i>	9	Catmull, E., et al., "Recursively generated B-spline surfaces on arbitrary topological meshes," Computer Aided Design, Vol. 10, Pages 350-355, 1978.
	10	Halstead, Mark, et al., "Efficient, Fair Interpolation using Catmull-Clark Surfaces," Computer Graphics (SIGGRAPH Proceedings), Pages 35-44, 1993.
	11	Havemann, Sven, "Interactive Rendering of Catmull/Clark Surfaces with Crease Edges," Computer Graphics, TU Braunschweig, February 2001.
	12	King, Davis et al., "An Architecture for Interactive Tetrahedral Volume Rendering," HP Laboratories Palo Alto, HPL-2000-121 (R.3), August 2, 2001.
	13	Lindholm, et al., "A User-Programmable Vertex Engine," ACM SIGGRAPH 2001, Pages 149-158, August 2001.
<i>hm</i>	14	Moreton, Henry, "Watertight Tessellation using Forward Differencing," SIGGRAPH/EUROGRAPHICS Workshop on Graphics Hardware, Pages 25-32, 2001.

Examiner <i>K. Tung</i>	Date Considered <i>12/22/04</i>
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.